

# DP4

## **Precision Polishing System**

The Logitech DP4 is a high speed polishing system for semi automated final stage polishing of hard materials, such as sapphire, silicon carbide or gallium nitride, to epitaxy ready quality surfaces.

Each of it's four heads can process material up to 200mm / 8" Ø (or multiple smaller samples) and is capable of applying up to 50Kg of download on each carrier head, resulting in the DP4 having the highest sample throughput of any of our polishing systems.

### **Reduced Processing Times**

Processing times for materials such as sapphire, silicon carbide (SiC) and gallium nitride (GaN) are notoriously lengthy due to their hardness. The solution to this problem comes in the shape of the DP4 precision polishing system.

The four processing stations allow a high number of substrates or components to be polished with repeatable surface flatness and material removal rates, making it ideal for high volume production. Furthermore, it's ability to polish both hard and soft materials ensures it can work with virtually any optical or semiconductor material.

Each of the DP4's individual processing heads has built-in compression polishing technology, and can dramatically reduce processing times from anywhere between 70-400% over more traditional methods. For example, a theoretical throughput of approximately 144 polished 50mm / 2" Ø sapphire wafers per 8 hour shift can be achieved\*.

### **User Friendly Interface**

The DP4's advanced touch screen user interface has been designed to provide as much flexibility as possible, with increased control and automation available via both manual and automatic modes.

The manual mode provides access to individual process variables, thereby allowing operators to have extremely close control over process parameters. The automatic mode allows for complex, linked recipes to be created and stored in memory. This provides the operator with the ability to build a recipe library of automated and repeatable processes, and free up time to work on other tasks, safe in the knowledge that the samples will be polished to the required specification.

## **Industry Standard System Architecture**

Door interlocks are installed, ensuring current health and safety regulations are adhered to, while the built-in fume cabinet caters for processes involving toxic materials.

Furthermore, the DP4 is designed with chemo-mechanical based polishing processes in mind, as all parts and components are sodium hypochlorite resistant. An internal peristaltic pump is incorporated to deliver the slurry to the processing pad.



- Driven head technology dramatically reduces polishing time for hard materials
- Process up to 48 x 50mm / 2" Ø wafers or
   4 x 200mm / 8" Ø wafers per run
- Ideal for polishing SiC, GaN, AIN and Sapphire
- Automated process recipes increase system flexibility, repeatability and usability

#### **Typical Applications**

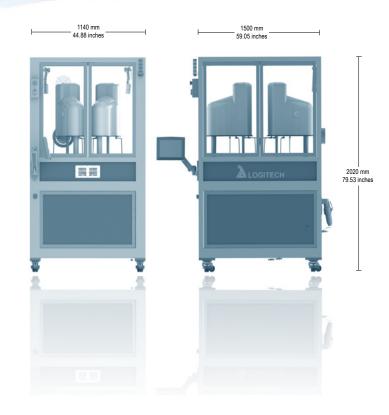
As a high capacity unit, the DP4 is ideal for production environments and it offers a highly effective solution to those seeking to polish materials or components traditionally viewed as being hard to process.

With it's variable download control, driven head technology and in-built automation, the DP4 is extremely versatile and is capable of being used with a wide range of polishing materials.

# **Precision Polishing System**



## **Technical Specifications**



# **Ordering Information**

**1DP4** DP4 Precision Polishing Machine

## Accessories & Components

**1PDP4S-0100** Plain plate base, (700mm / 27.6" Ø)

**1PDE4-0400** Grooved polyurethane polishing plate(700mm/27.6" Ø)

**1PDE4-0500** Non-Grooved polyurethane

polishing plate(700mm/27.6" Ø)

 1DP4T-0100
 Single wafer template kit (one kit required per head)

 1DP4T-0200
 Multiple wafer template kit (one kit required per head)

 1DPAC-0300
 Wafer mounting plate, for up to 200mm / 8" Ø wafers

1DPAC-0400 Diamond conditioning plate

### Consumables

0CON-137 SF1 Polishing Fluid, 25 ltrs0CON-141 Chemlox Polishing Fluid, 4 ltrs

**0CON-392** Cross Hatched, Grooved Polyurethane Polishing Pad,

700mm / 27.6" Ø

**0CON-358** Chemcloth Polishing Cloth, 700mm / 27.6" Ø, (x10)

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